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Reference 3:

JP Patent Application Disclosure No. 6-503048 - April 7, 1994

Application No. 4-502487 - January 16, 1992

PCT Application No. PCT/EP92/00080

PCT Appln. Disclosure No. WO92/13694 - August 20, 1992

Priority: February 7, 1991, DE (Application No. P4103602.6)

Applicant: Wacker-Chemie GmbH, DE

Title: Process for the continuous preparation of HTV silicone
material

Process for the continuous preparation of HTV silicone compositionsPatent Number: ☐ US6124392

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Applicant(s): WACKER CHEMIE GMBH (DE)

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IPC Classification: C08K3/34

EC Classification: C08J3/20Equivalents: CS9200034, ☐ DE4103602, ☐ EP0570387 (WO9213694), B1, ES2065774T, JP2531912B2, JP6503048T, KR9700921, ☐ RU2091222**Abstract**

PCT No. PCT/EP92/00080 Sec. 371 Date Jun. 10, 1993 Sec. 102(e) Date Jun. 10, 1993 PCT Filed Jan. 16, 1992 PCT Pub. No. WO92/13694 PCT Pub. Date Aug. 20, 1992 The invention relates to a process for the continuous preparation of HTV silicone compositions, which comprises mixing and homogenizing 100 parts by weight of diorgano(poly)siloxane which has a viscosity of 50 to 100,000 Pas at 25 DEG C. with at least 20 parts by weight of finely divided silicon dioxide which has a tamped density of more than 0.01 kg/l in an oscillating single-shaft pilgrim-step kneader.

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